

Fig. 1

Tangential Flow

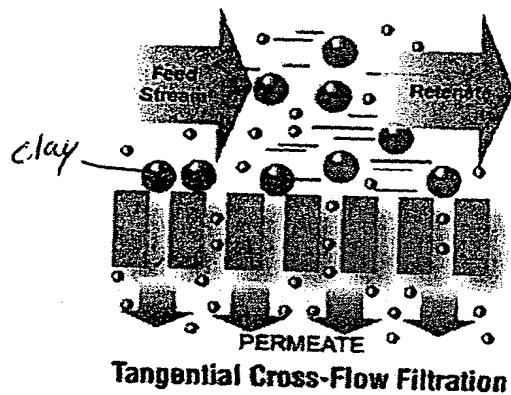


Fig. 2

Polishing Results

Purified Ca-Mont. as Abrasive in Cu CMP Slurry

Cu RR vs. H₂O₂%
pH=9, 1%Ca-Mont., 1% Glycine

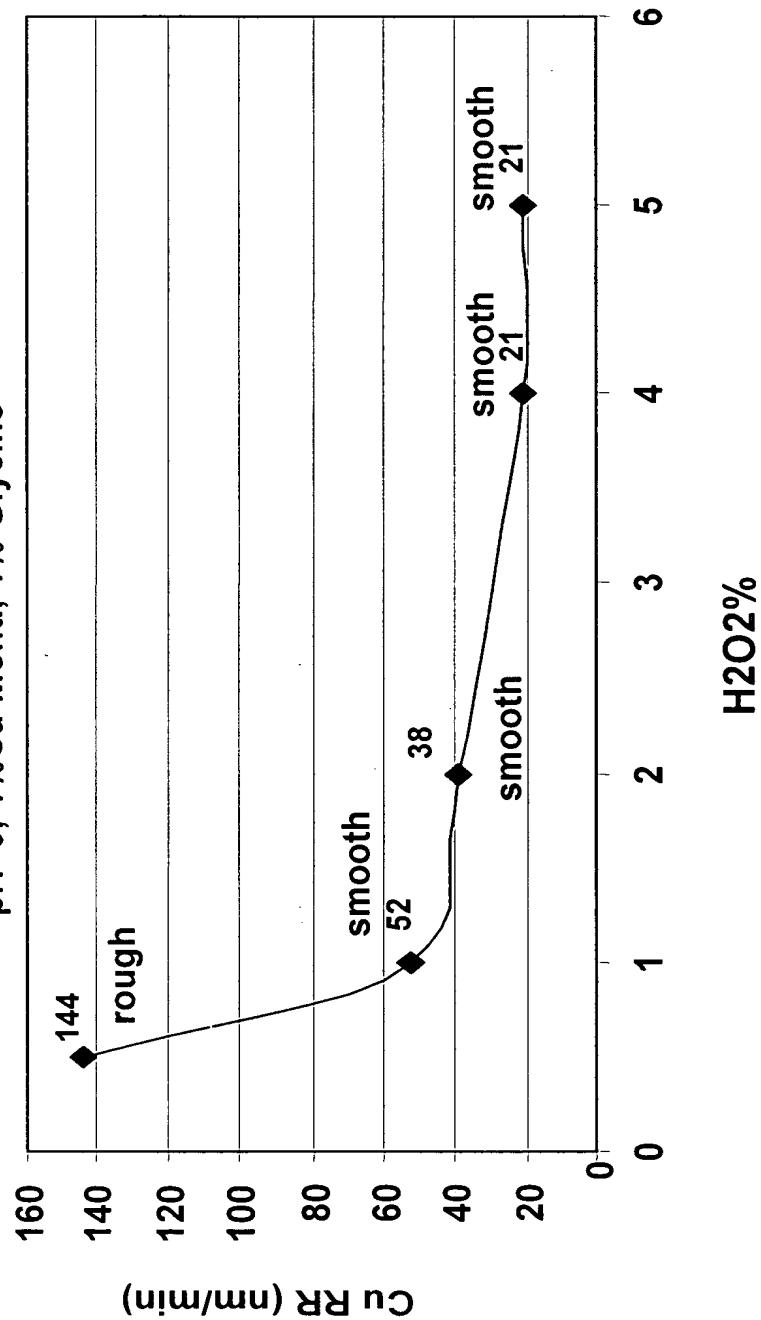


Fig. 3

Polishing Results

Purified Ca-Mont. as Abrasive in Cu CMP Slurry
Cu RR vs. pH and H₂O₂%
1%Ca-Mont., 1% Glycine

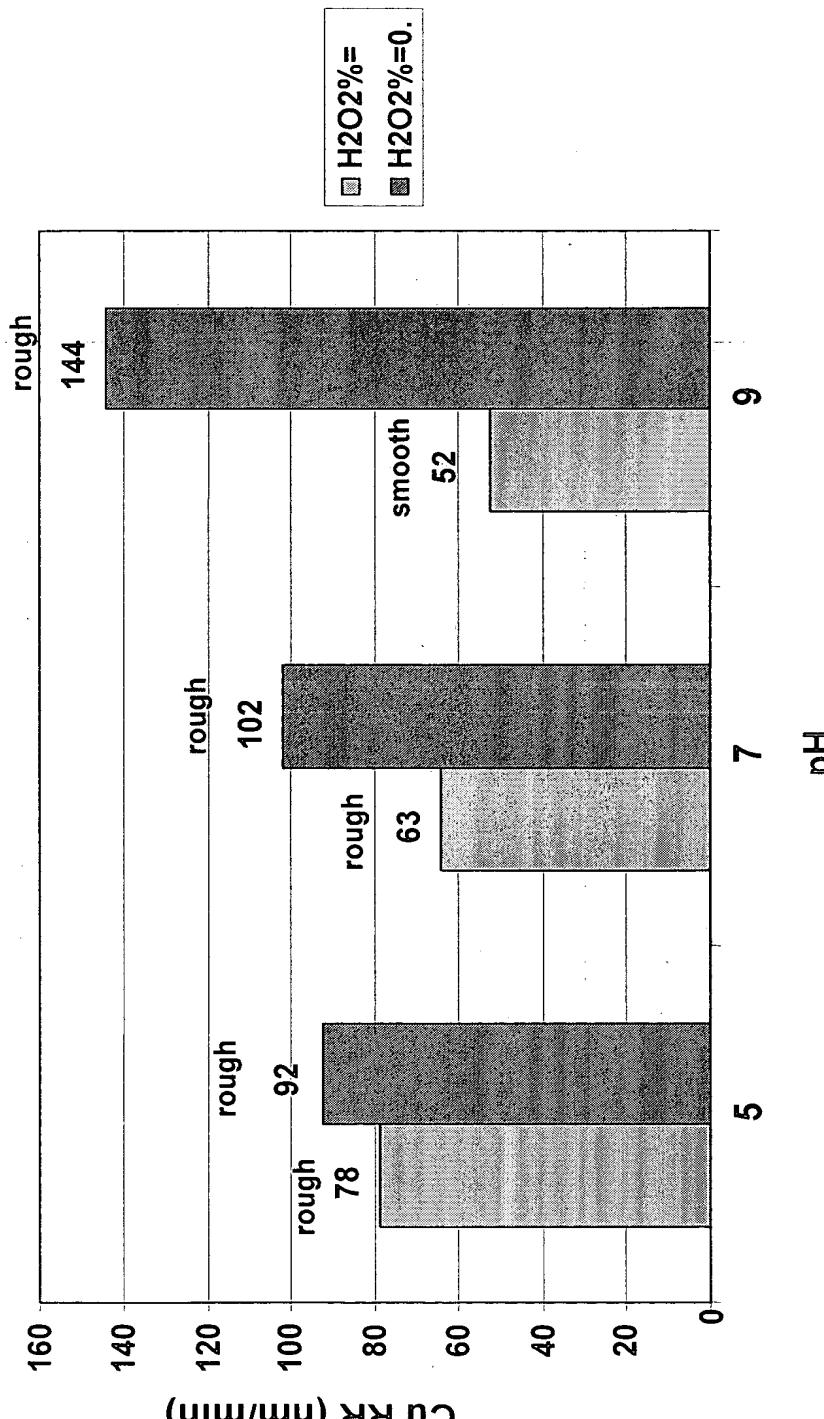


Fig. 4